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- (71) Applicant (for all designated States except US): SHOWA DENKO K.K. [JP/JP]; 13-9, Shiba Daimon 1-chome, Minato-ku, Tokyo 105-8518 (JP).
- (72) Inventors; and
- (75) Inventors/Applicants (for US only): KUSUNOKI, Katsuki [JP/JP]; c/o Showa Denko HD K.K., 5-1, Yawata Kaigan dori, Ichihara-Shi, Chiba 290-0067 (JP). MITANI, Kazuhiro [JP/JP]; c/o Showa Denko HD K.K., 5-1, Yawata Kaigan dori,, Ichihara-Shi, Chiba 290-0067 (JP). UDAGAWA, Takashi [JP/JP]; C/o Showa Denko K.k., 1505, Shimokagemori, Chichibu-shi, Saitama 369-1871 (JP).

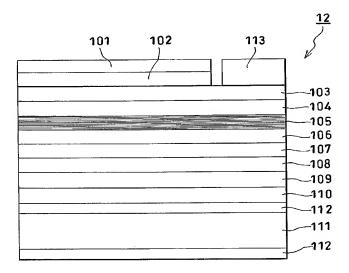
- (74) Agents: FUKUDA, Kenzo et al.; Kashiwaya Bldg., 6-13, Nishishinbashi 1-chome, Minato-ku, Tokyo 105-0003 (JP).
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(54) Title: GROUP III NITRIDE SEMICONDUCTOR LIGHT-EMITTING DEVICE AND METHOD OF PRODUCING THE SAME



(57) Abstract: A Group III nitride semiconductor light-emitting device includes a stacked structure 11 formed on a crystal substrate (100) to be removed from it and including two Group III nitride semiconductor layers 104 and 106 having different electric conductive types and a light-emitting layer 105 which is stacked between the two Group III nitride semiconductor layers and which includes a Group III nitride semiconductor, and a plate body 111 made of material different from that of the crystal substrate and formed on a surface of an uppermost layer which is opposite from the crystal substrate that is removed from the stacked structure.



